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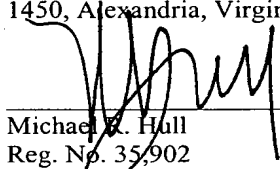
1752

PATENT
30205/37675

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Keun Kyu Kong et al.)
Serial No.: 10/006,633)
Filed: December 5, 2001)
For: Pattern Width Slimming-)
Inhibiting Method of Photoresist Pattern)
Using Photoresist Composition)
Containing Thermal Acid Generator)
Group Art Unit: 1752)
Examiner: Amanda C. Walke)

I hereby certify that this paper and the documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on February 5, 2004, in an envelope addressed to Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450


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AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

This paper is filed in response to the office action mailed on November 5, 2003. Please amend the above-identified patent application as follows: